



Patent Application No. 10/692,030
Customer Number: 42717

IFW

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant:	Syun-Ming Jang, et al.	§	Docket No.:	24061.468
		§		(TSMC2002-0130)
Serial No.:	10/692,030	§		
		§	Examiner:	Calvin Lee
Filing Date:	October 23, 2003	§		
		§	Art Unit:	2825
For:	SiOC Properties and Its Uniformity	§		
	in Bulk for Damascene	§	Conf. No.:	6421
	Applications	§		

RESPONSE TO RESTRICTION REQUIREMENT

Mail Stop: Amendment
Commissioner for Patents
PO Box 1450
Alexandria, VA 22313-1450

Dear Sir:

In response to the Office Action mailed January 26, 2004, applicant hereby elects Group I, Claims 1-31, which is drawn to a method of forming a dielectric material layer.

Applicant's election is made with traverse on the grounds that the embodiments delineated by the examiner are not patentably distinct and therefore constitute a single invention concept.

An early action on the merits is respectfully requested.

Respectfully submitted,

Timothy F. Bliss

Timothy F. Bliss
Reg. No. 50,925

Date: 10/8/04

HAYNES AND BOONE, LLP
901 Main Street, Suite 3100
Dallas, Texas 75202-3789
Telephone: 972-739-8638
Facsimile: 214-200-0853

CERTIFICATE OF MAILING

I hereby certify that this correspondence is being deposited with the United States Postal Service as first class mail in an envelope addressed to: Mail Stop: Amendment, Commissioner For Patents, PO Box 1450, Alexandria, VA 22313-1450 on the date below.

Dayle Conner
Name

10-8-04
Date